

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Robert David Allen et al.	Examiner:	John S. Y. Chu
Serial No.: 10/729,452	Group Art Unit:	1752
Filing Date: December 4, 2003	Confirmation No:	2060
Title: METHOD FOR PATTERNING A LOW ACTIVATION ENERGY PHOTORESIST		

**AMENDMENT UNDER 37 CFR § 1.111
AND REQUEST FOR EXTENSION OF TIME**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is in response to the Office Action mailed from the PTO on August 10, 2007. A two-month extension of time is requested. The fee for the extension accompanies this response. Please amend the application as indicated herein.

The *Listing of the Claims* begins on page 2 of this document. Amendments to the claims are reflected therein. With this amendment, claim 1 has been amended.

Remarks begin on page 12 of this document.